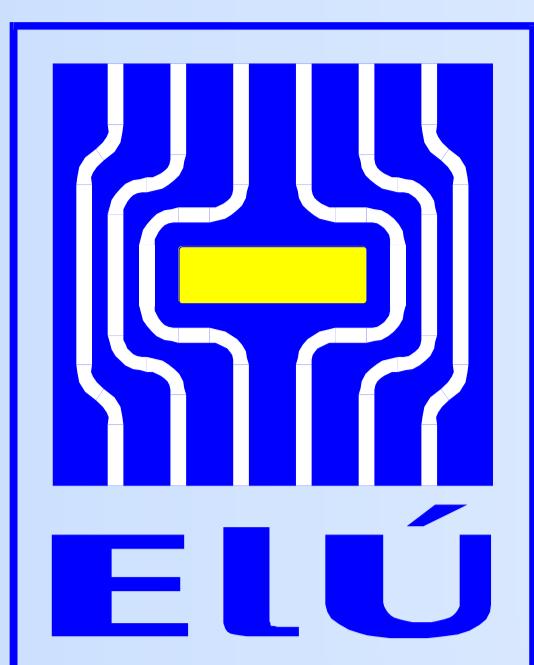


Imaging and spectrometric performance of SiC Timepix3 radiation camera



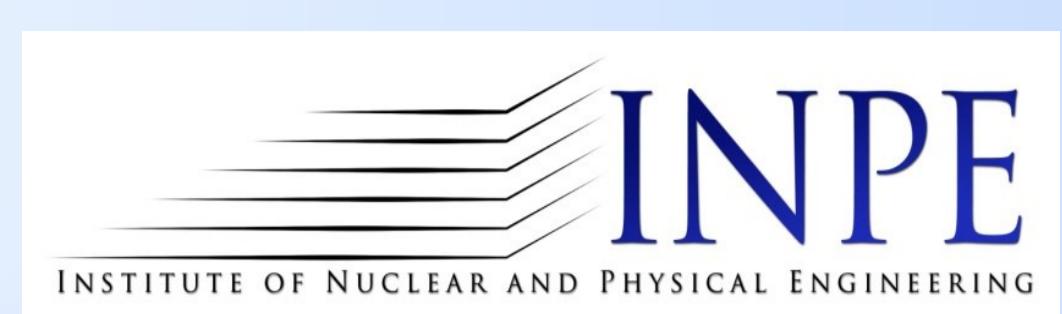
Bohumír Zaťko^{1,*}, Andrea Šagátová², Nikola Kurucová², Andrej Novák², Eva Kováčová¹

elekzbzat@savba.sk

¹Institute of Electrical Engineering, Slovak Academy of Sciences, Dúbravská cesta 9, SK-814 04 Bratislava, Slovak Republic

²Institute of Nuclear and Physical Engineering, Faculty of Electrical Engineering and Information Technology, Slovak

University of Technology, Ilkovičova 3, SK-812 19 Bratislava, Slovak Republic



INTRODUCTION

Detectors based on 4H-SiC (Silicon Carbide) are very perspective due to:

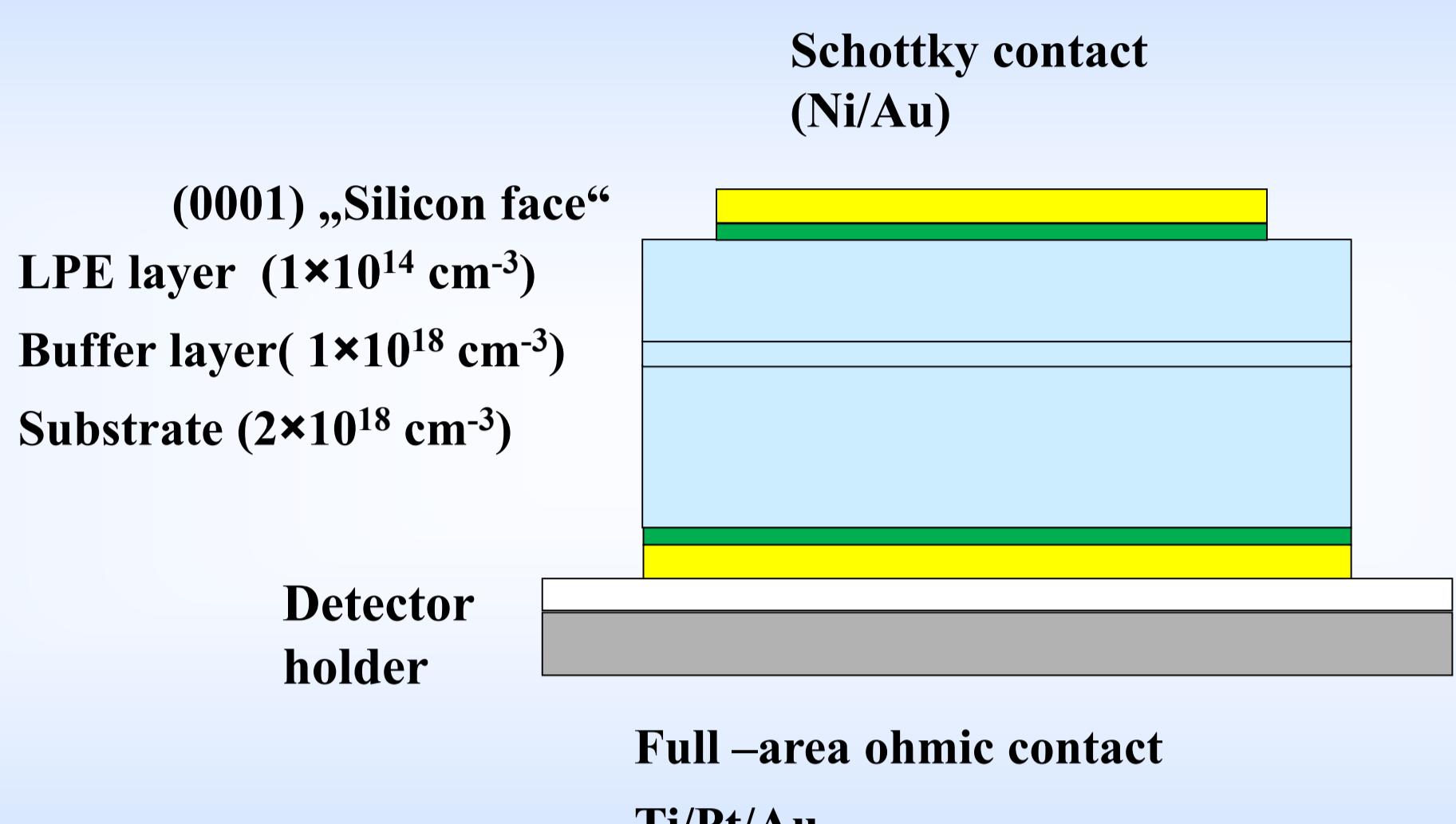
- high breakdown voltage (4×10^6 V/cm)
- electron mobility of about $900 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$
- high electron saturation drift velocity ($2 \times 10^7 \text{ cm s}^{-1}$)
- band gap energy of 3.26 eV
- operation at increased temperature up to 500°C
- good radiation hardness

DETECTOR MATERIAL

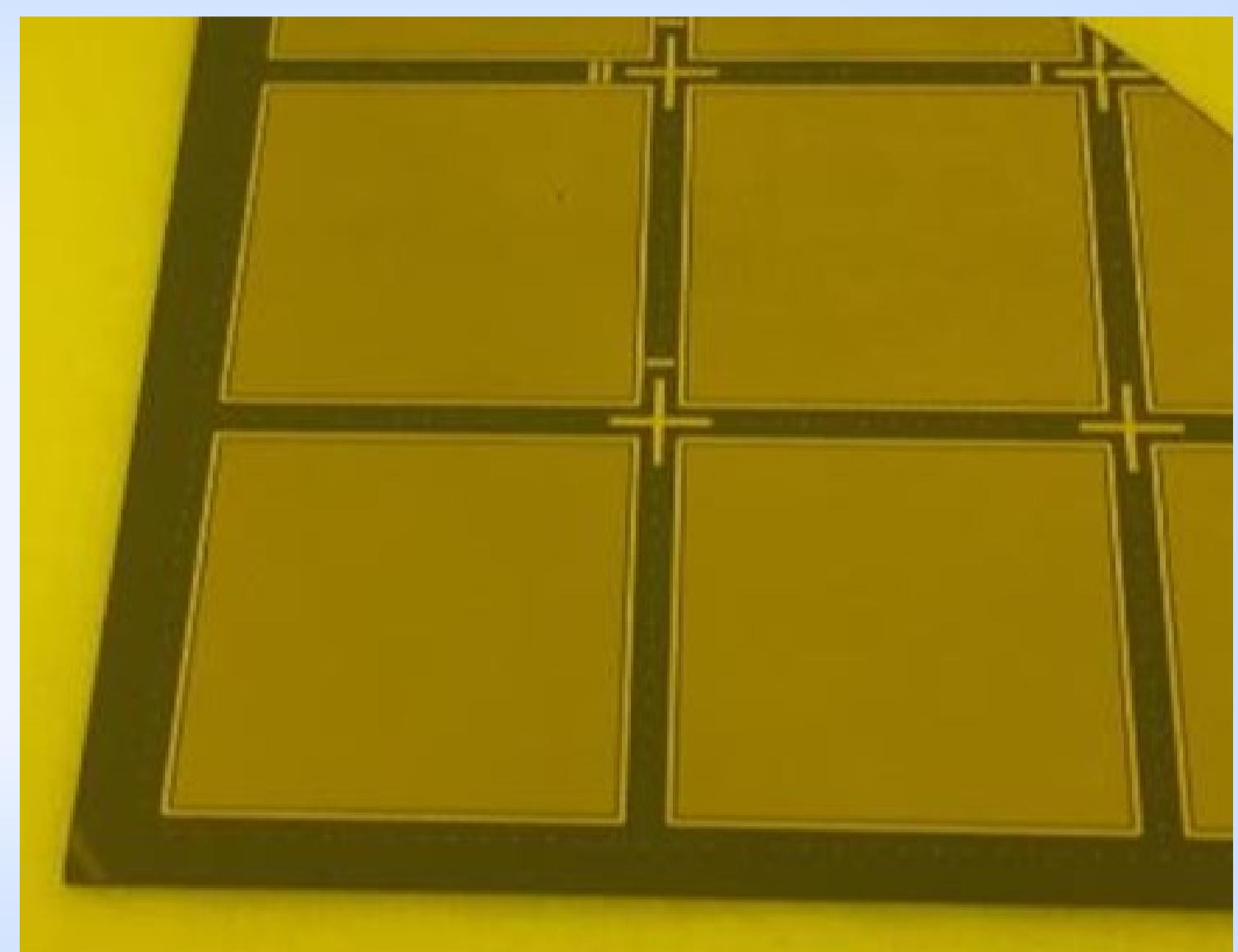
Base material parameters:

- 80 μm thick nitrogen-doped 4H–SiC layer grown by LPE
- Doping concentrations about $7 \times 10^{13} \text{ cm}^{-3}$ and $3 \times 10^{14} \text{ cm}^{-3}$
- 4H-SiC n⁺ substrate (350 μm thick)
- 0.5 μm buffer layer n⁺-SiC with concentration $1 \times 10^{18} \text{ cm}^{-3}$

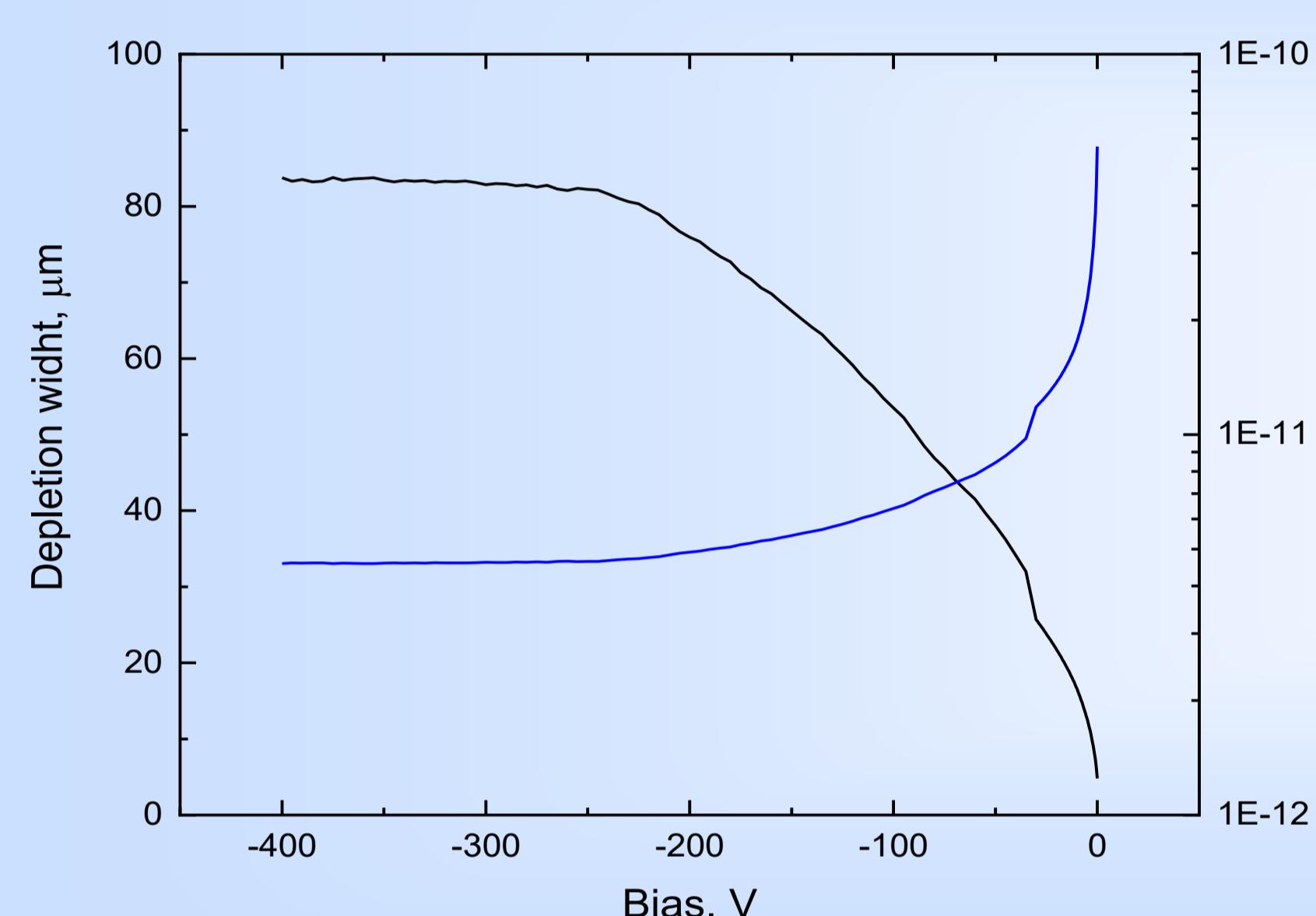
CROSS-SECTION OF DETECTOR



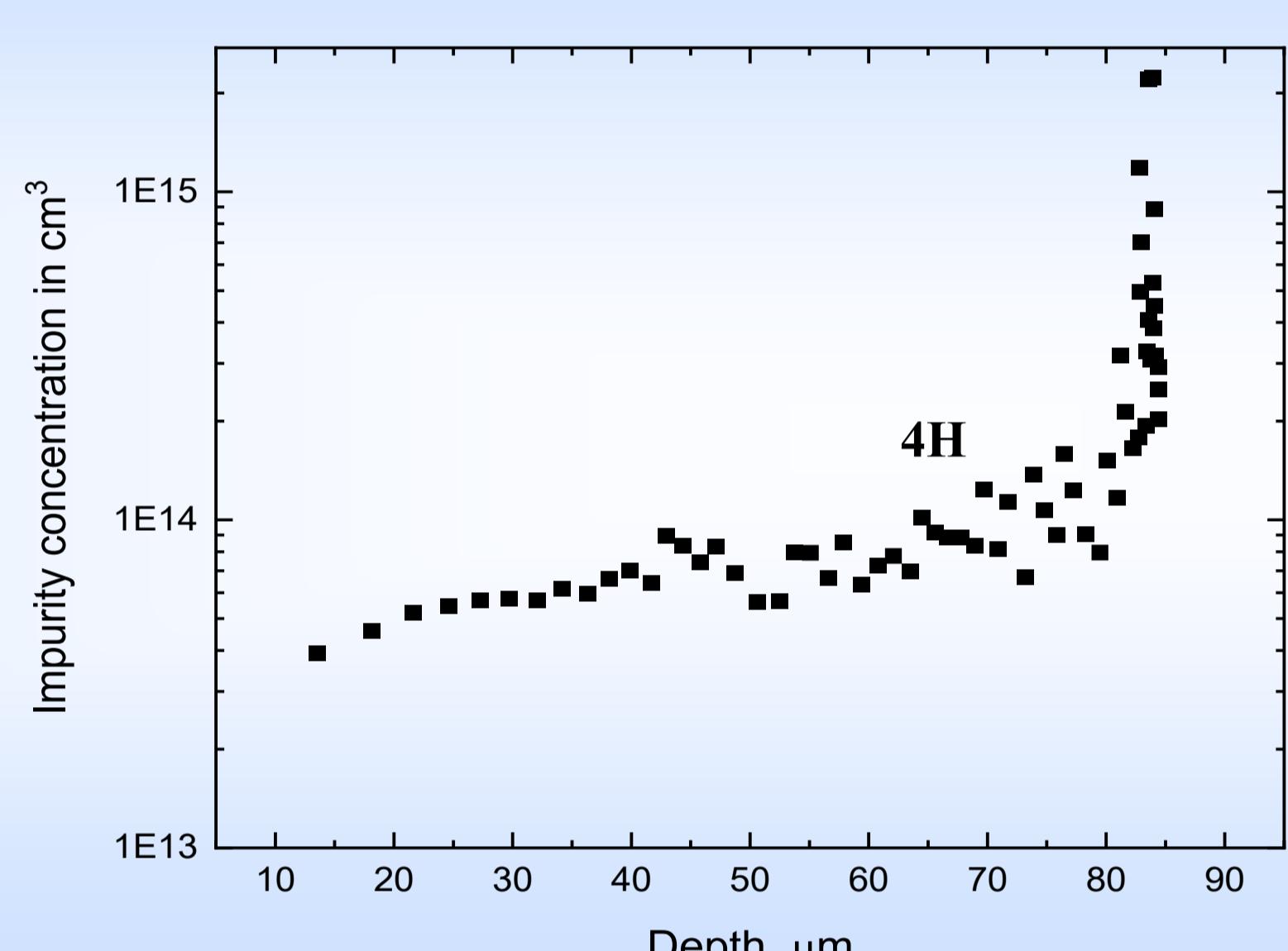
PHOTOGRAPH OF PIXEL DETECTOR



CAPACITANCE-VOLTAGE MEASUREMENTS DEPLETION THICKNESS



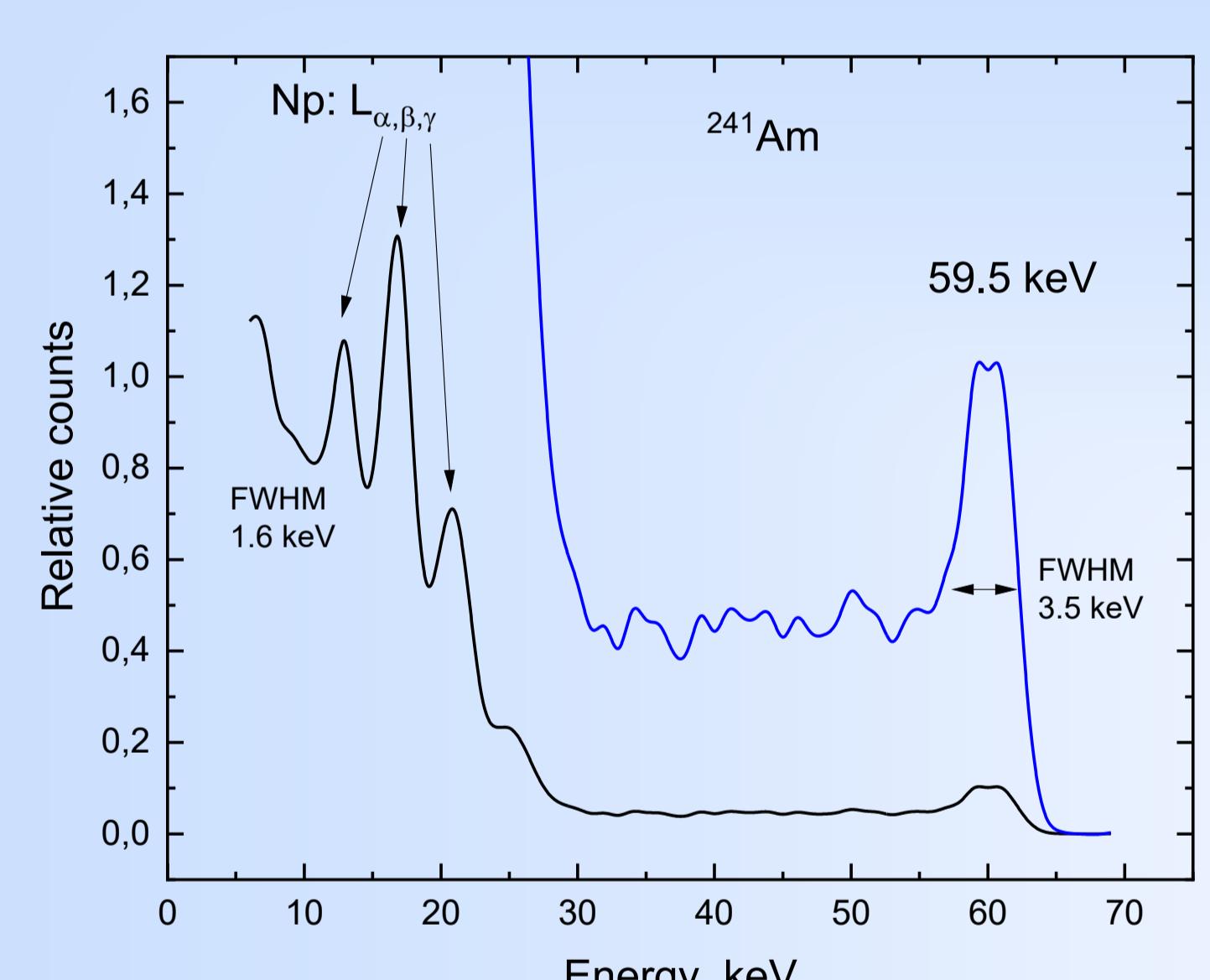
CONCENTRATION PROFILE



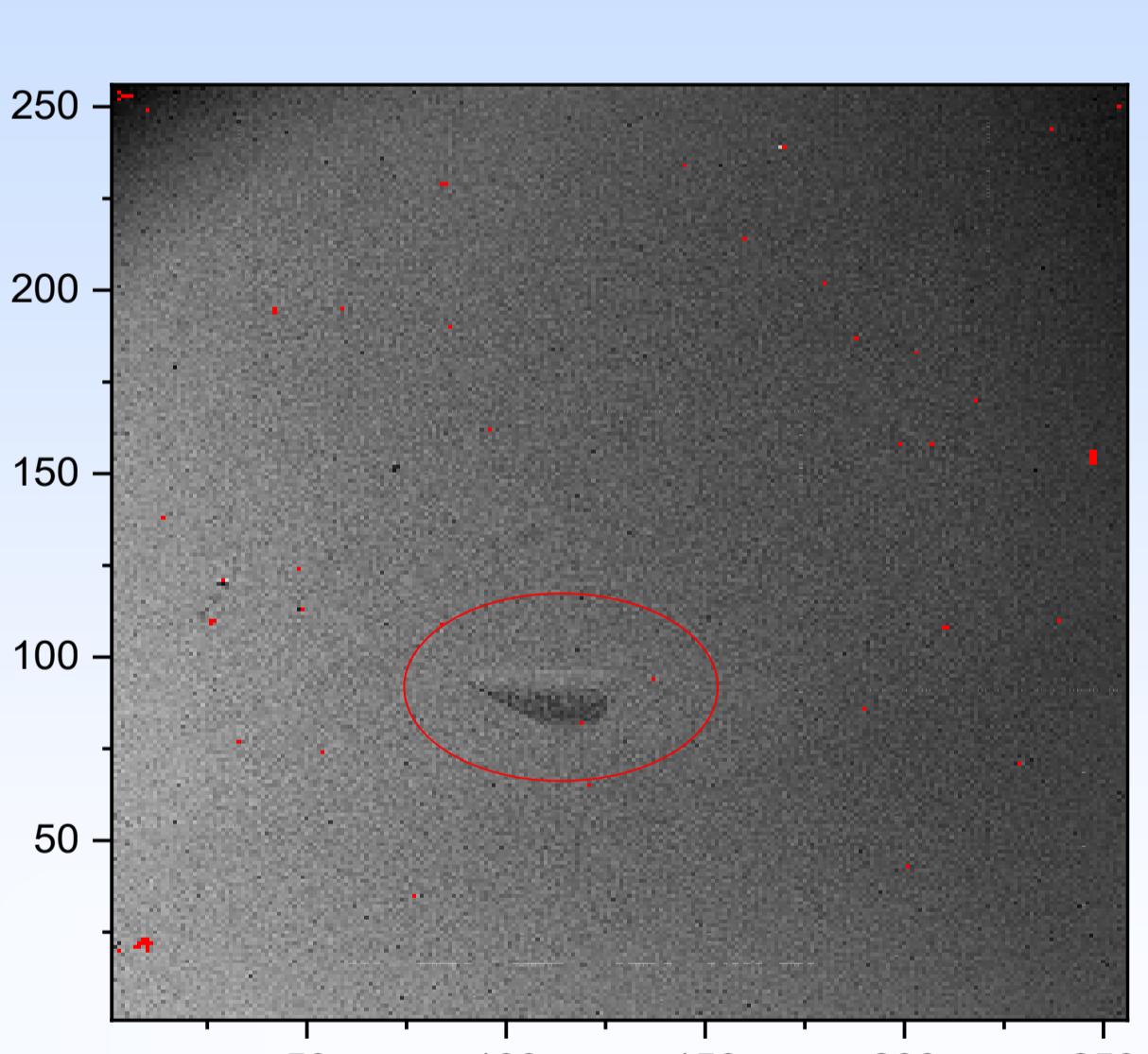
TIMEPIX3 DETECTOR IMAGE



THRESHOLD SCAN



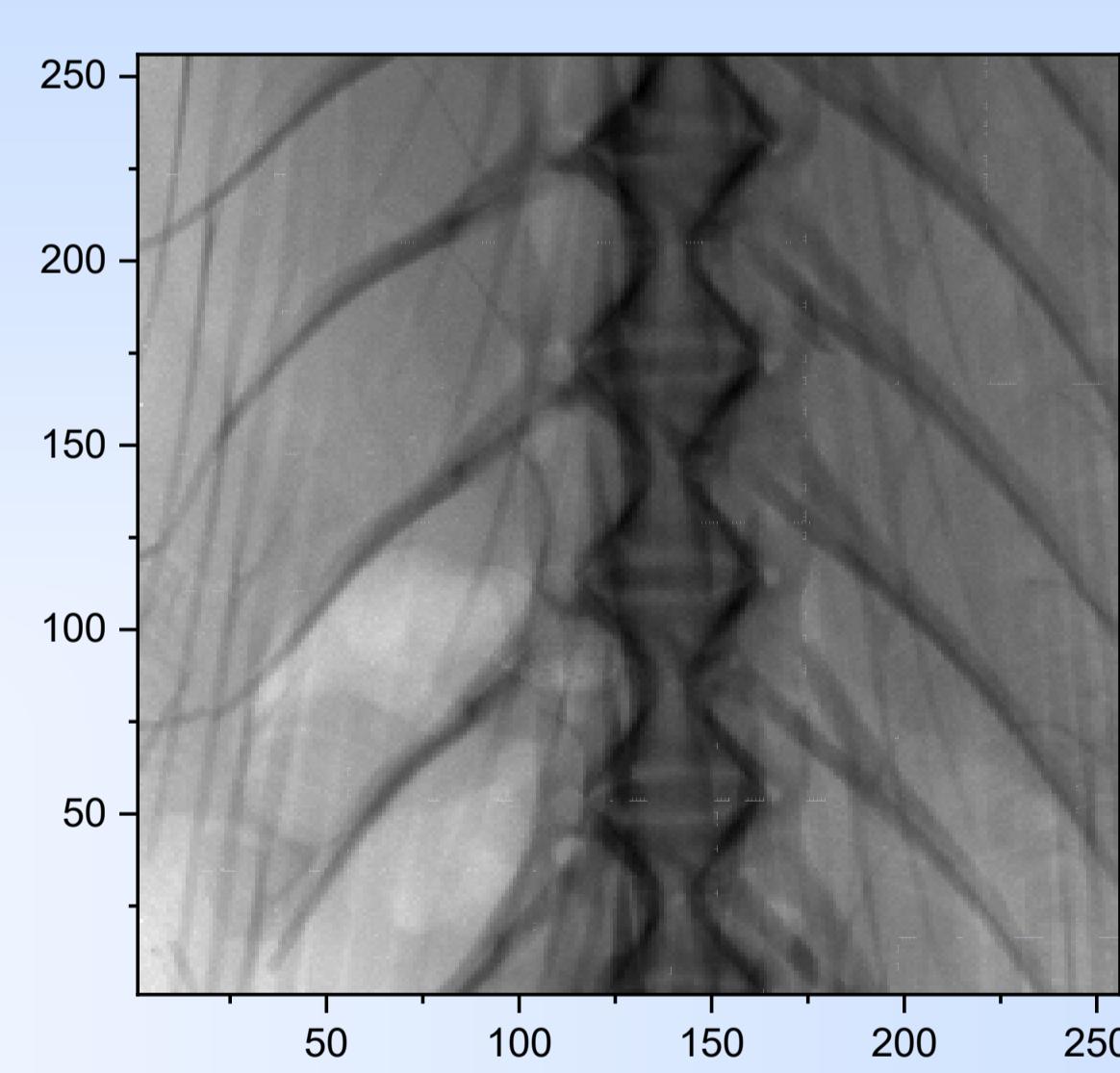
OPEN BEAM ILLUMINATION



Color Scale

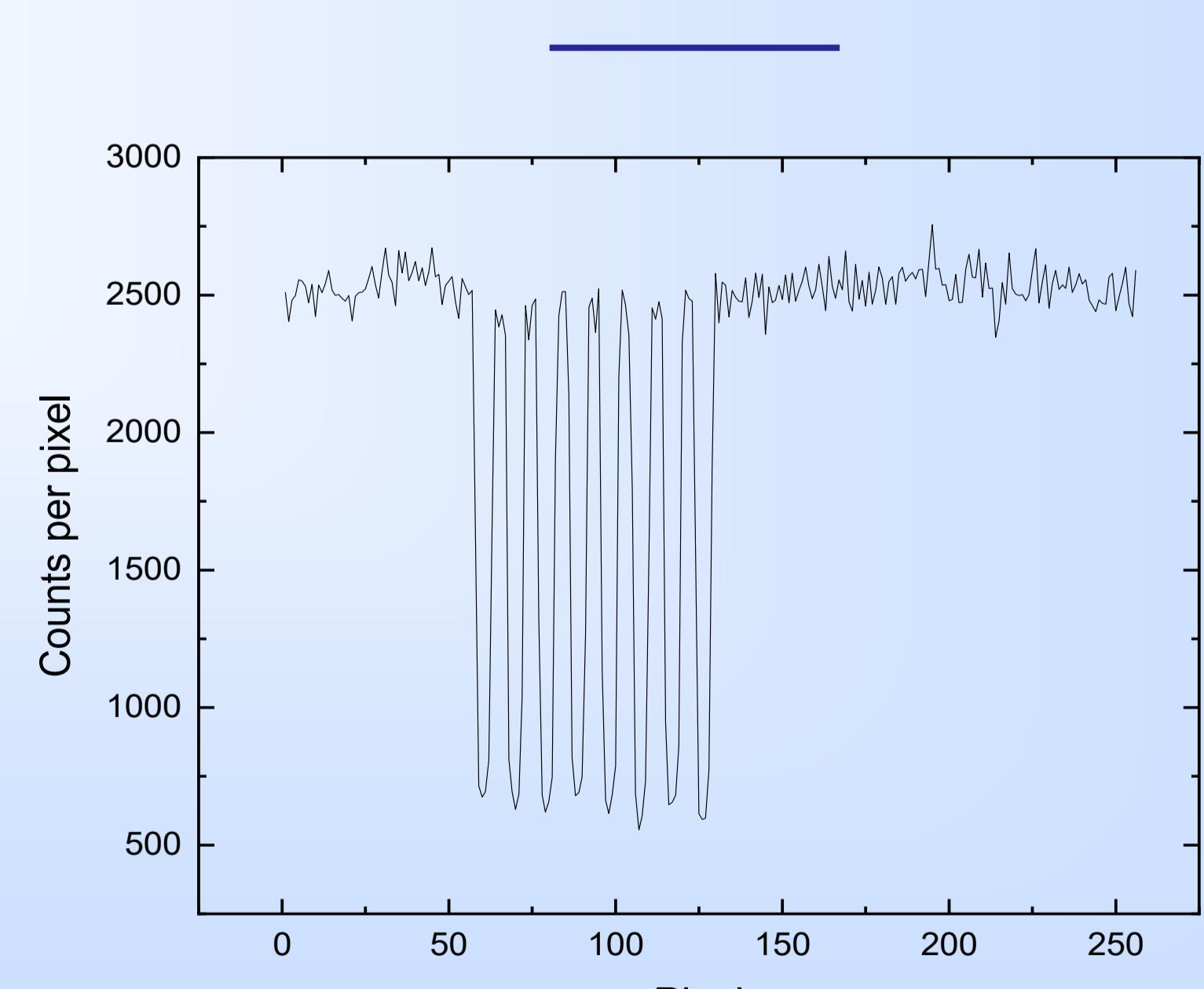
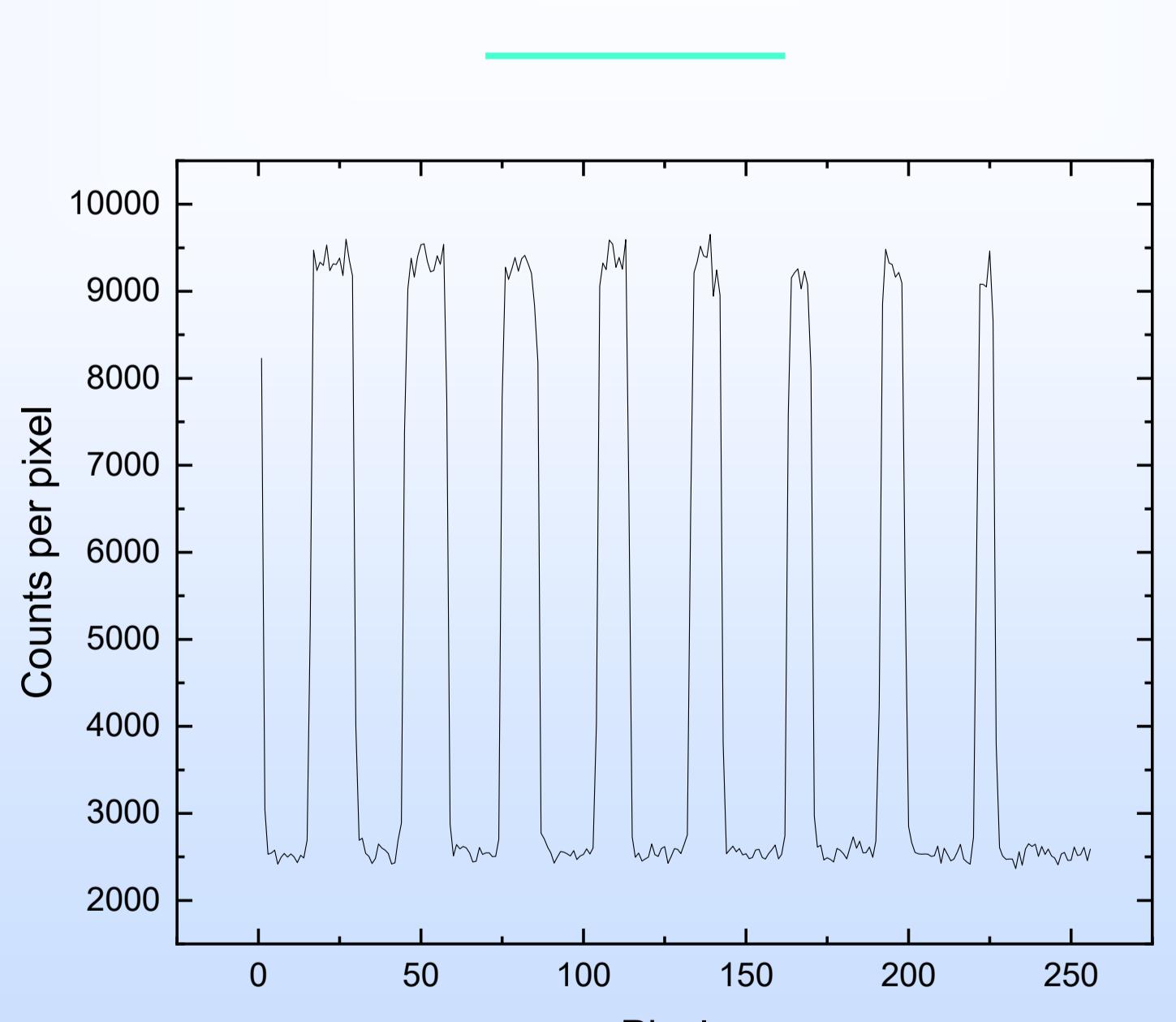
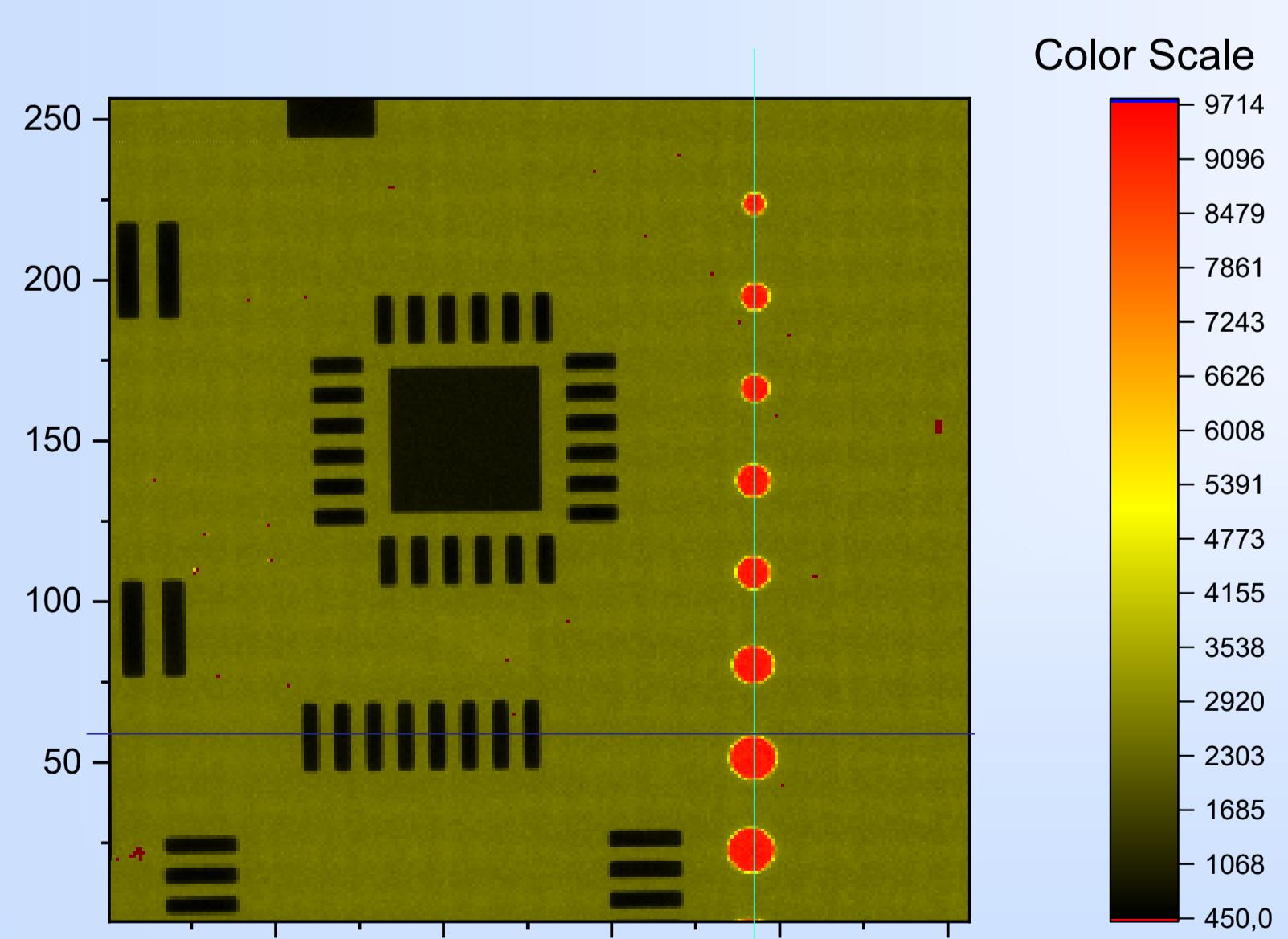
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158082
151076
144070
137064
130059
123053
116047
109041
102035
95029
88023
81018
74012
67006
60000

X-RAY IMAGE OF FISH



37291
35445
33599
31753
29907
28061
26215
24369
22523
20677
18830
16984
15138
13292
11446
9600

TESTING OBJECT



SUMMARY AND CONCLUSIONS

- We fabricated semiconductor detectors based on 4H-SiC epitaxial layer.
- Active layer consists of 4H-SiC LPE with thickness up to 80 μm .
- The lowest doping concentration is below $7 \times 10^{13} \text{ cm}^{-3}$.
- Detectors can obtain high energy resolution comparable to silicon detectors.
- We fabricated pixelated structures based on high-quality 4H-SiC epitaxial layer.
- Structures were bump-bonded to Timepix3 readout chips.
- The SiC Timepix3 detector shows high resolution comparable to silicon sensor.
- X-ray images show excellent quality and stable operation during long time.